



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : **Confirmation No. 1092**
Hiroto YUKAWA et al. : Docket No. 2004_0499
Serial No. 10/810,902 : Group Art Unit 1752
Filed March 29, 2004 : Examiner Sin J. Lee

POSITIVE-WORKING CHEMICAL-
AMPLIFICATION PHOTORESIST
COMPOSITION

Mail Stop: Amendment

RESPONSE

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Official Action dated April 8, 2005, please amend the present application as follows: